## **AMENDMENTS TO CLAIMS**

- Claim 1. (Currently Amended) A method of making glycosides using a non-cryogenic process comprising, in a continuous process, the steps of:
- (a) lithiating an aromatic reactant having a leaving group using a lithium reagent in a first microreactor at non-cryogenic temperatures to form a lithiated anion species; and
- (b) coupling the lithiated anion species with a carbonyl substituted reactant <u>at non-cryogenic temperatures</u> to form a glycoside.
- Claim 2. (Original) The method according to claim 1, wherein said lithiating step is performed at a temperature of from about -10°C to about 20°C.
- Claim 3. (Original) The method according to claim 2, wherein said lithiating step is performed at a temperature of from about -10°C to about 5°C.
- Claim 4. (Original) The method according to claim 1, wherein the residence time in said first microreactor is from about 2 seconds to about 3 seconds.
- Claim 5. (Original) The method according to claim 1, wherein said aromatic reactant is a halide.
- Claim 6. (Original) The method according to claim 1, where said lithium reagent is selected from the group consisting of n-BuLi and t-BuLi.
  - Claims 7-9. (Cancelled).
- Claim 10. (Original) The method according to claim 1, wherein said coupling step is performed in a second microreactor under non-cryogenic conditions.

Claim 11. (Original) The method according to claim 10, wherein said coupling step is performed at a temperature of from about -20°C to about 20°C.

Claim 12. (Original) The method according to claim 11, wherein said coupling step is performed at a temperature of about -10°C.

Claim 13. (Original) The method according to claim 10, wherein the residence time in said second microreactor is from about 2 seconds to about 3 seconds.

Claim 14. (Original) The method according to claim 10, wherein a yield of said glycoside is greater than about 70%.

Claim 15. (Currently Amended) A method of making glycosides using a non-cryogenic process comprising, in a continuous process, the steps of:

- (a) lithiating an aromatic reactant having a leaving group using a lithium reagent at noncryogenic temperatures to form a lithiated anion species; and
- (b) coupling the lithiated anion species with a carbonyl substituted reactant according to formula IV

## wherein

 $X_1$  is a heteroatom;

R2 is a substituted or unsubstituted alkyl group; and

<u>PG is a protective group,</u> in a microreactor under non-cryogenic <del>conditions</del> temperatures to form a glycoside.

Claim 16. (Original) The method according to claim 15, wherein said coupling step is performed at a temperature of from about -10°C to about 20°C.

Claim 17. (Original) The method according to claim 15, wherein said coupling step is performed at a temperature of from about -10°C to about 5°C.

Claim 18. (Original) The method according to claim 15, wherein the residence time in said microreactor is from about 2 seconds to about 3 seconds.

Claim 19. (Cancelled).

Claim 20. (Original) The method according to claim 1, further comprising the step of:

(c) deprotecting the glycoside.

Claim 21. (Original) A glycoside formed by the method of claim 1.

Claim 22. (Currently Amended) A continuous process for making a glycoside having the general structural formula [I]:

[I]

wherein:  $R_1$  is hydrogen,  $NO_2$ ,  $OR_4$ , a halogen, or a substituted or non-substituted alkyl, aryl, or heterocycle;  $R_2$  is a substituted or non-substituted alkyl group;  $R_4$  is a substituted or non-substituted alkyl or aryl;  $X_1$  is a heteroatom; and PG is a protective group, the method including the steps of:

(a) reacting an aromatic reactant having general structural formula [II]:

$$X_2$$
 [II]

wherein:  $R_1$  is as defined previously and  $X_2$  is a leaving group, in a first microreactor with an organo lithium reagent at non-cryogenic temperatures to form a lithiated anion species having general structural formula [III]:

wherein R<sub>1</sub> is as defined previously, and

(b) coupling the lithiated anion species [III] with a carbonyl substituted compound having general structural formula [IV]:

wherein:  $R_2$ ,  $X_1$  and PG are as described previously, <u>at non-cryogenic temperatures</u> to form the compound having general structural formula [I].

- Claim 23. (Original) The method of claim 22 wherein the lithiating step is performed at a temperature of from about -10°C to 20°C.
- Claim 24. (Previously Presented) The method of claim 23 wherein the coupling step is performed in a second microreactor at non-cryogenic temperatures.
- Claim 25. (Original) The method of claim 23 wherein the lithiating step is conducted in a solvent selected from THF/toluene or THF/heptane.

- Claim 26. (Previously Presented) The method of claim 23 wherein the coupling step is performed in a second microreactor at non-cryogenic temperatures.
- Claim 27. (Original) The method of claim 26 wherein the coupling step is performed at a temperature of from about -20°C to 20°C.
  - Claim 28. (New) The method of claim 15 wherein PG is a per(silyl) group.
  - Claim 29. (New) The method of claim 28 wherein PG is Me<sub>3</sub>Si, Et<sub>3</sub>Si or Me<sub>2</sub>SiBu-t.
  - Claim 30. (New) The method of claim 22 wherein PG is a per(silyl) group.
  - Claim 31. (New) The method of claim 30 wherein PG is Me<sub>3</sub>Si, Et<sub>3</sub>Si or Me<sub>2</sub>SiBu-t.